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Sheet 1 of 1

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APPLICANT(S): John P. O'Loughlin et al.

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U.S. PATENT DOCUMENTS

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EXAMINI INITIAI		DOCUMENT NUMBER					IBER	1	DATE	NAME	CLASS		SUB CLASS	IF APPROPRIATE
1)	3	8	0	7	7	5	5	Apr. 30, 1974	Mason, Jr.	2	80	150AB	•
	-	5	4	3	3	4	7	6	Jul. 18, 1995	Materna et al.		i	736	
		5	5	5	1	7	2	5	Sep. 3, 1996	Ludwig		1	737	
		5	5	6	6	9	7	6	Oct. 22, 1996	Cuevas			4.1	
		5	7	8	8	2	7	0	Aug. 4, 1998	Haland et al.			729	
		5	8	0	6	8	8	3	Sep. 15, 1998	Cuevas			731	
	************	5	8	2	0	1	6	2	Oct. 13, 1998	Fink	П		742	
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		6	1	0	2	4	3	5	Aug. 15, 2000	Wallner et al.	П		730.2	
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		6	1	3	5	4	9	2	Oct. 24, 2000	Zimmerbeutel et al.	L	1	1.	
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74	2	3	1	4	3	0	0.	Α	24 Dec. 1997	Britain	-	/			
W										_					

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

A copy of a Research Disclosure dated December 1999 entitled AIR BAG FABRIC FOR USE WITH COLD GAS INFLATOR

EXAMINER

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EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP \$609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to the patent applicants' attorney.